

## SUPPLEMENT NO. 1 TO PART 713—SCHEDULE 2 CHEMICALS

A. Toxic chemicals:	
(1) Amiton: O,O-Diethyl S-[2-(diethylamino)ethyl] phosphorothiolate and corresponding alkylated or protonated salts .....	(78–53–5)
(2) PFIB: 1,1,3,3,3-Pentafluoro-2-(trifluoromethyl)-1-propene .....	(382–21–8)
(3) BZ: 3-Quinuclidinyl benzilate .....	(6581–06–2)
B. Precursors:	
(4) Chemicals, except for those listed in Schedule 1, containing a phosphorus atom to which is bonded one methyl, ethyl or propyl (normal or iso) group but not further carbon atoms, e.g. Methylphosphonyl dichloride .....	(676–97–1)
Dimethyl methylphosphonate .....	(756–79–6)
Exemption: Fonofos: O-Ethyl S-phenyl ethylphosphono-thiolothionate .....	(944–22–9)
(5) N,N-Dialkyl (Me, Et, n-Pr or i-Pr) phosphoramidic dihalides .....	
(6) Dialkyl (Me, Et, n-Pr or i-Pr) N,N-dialkyl (Me, Et, n-Pr or i-Pr)-phosphoramidates .....	
(7) Arsenic trichloride .....	(7784–34–1)
(8) 2,2-Diphenyl-2-hydroxyacetic acid .....	(76–93–7)
(9) Quinuclidine-3-ol .....	(1619–34–7)
(10) N,N-Dialkyl (Me, Et, n-Pr or i-Pr) aminoethyl-2-chlorides and corresponding protonated salts .....	
(11) N,N-Dialkyl (Me, Et, n-Pr or i-Pr) aminoethane-2-ols and corresponding protonated salts .....	
Exemptions: N,N-Dimethylaminoethanol and corresponding protonated salts .....	(108–01–0)
N,N-Diethylaminoethanol and corresponding protonated salts .....	(100–37–8)
(12) N,N-Dialkyl (Me, Et, n-Pr or i-Pr) aminoethane-2-thiols and corresponding protonated salts .....	
(13) Thiodiglycol: Bis(2-hydroxyethyl) sulfide .....	(111–48–8)
(14) Pinacolyl alcohol: 3,3-Dimethylbutane-2-ol .....	(464–07–3)

PART 714—ACTIVITIES INVOLVING  
SCHEDULE 3 CHEMICALS

## Sec.

- 714.1 Declaration on past production of Schedule 3 chemicals for chemical weapons purposes.
- 714.2 Initial and annual declaration requirements for plant sites that produce a Schedule 3 chemical in excess of 30 metric tons.
- 714.3 Initial and annual reporting requirements for exports and imports of Schedule 3 chemicals.
- 714.4 Advance declaration requirements for additionally planned production of a Schedule 3 chemical.
- 714.5 Frequency and timing of declarations.
- 714.6 Amended declaration or report.

SUPPLEMENT NO. 1 TO PART 714—SCHEDULE 3  
CHEMICALS

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§ 714.1 Declaration on past production  
of Schedule 3 chemicals for chemical  
weapons purposes.

(a) See § 711.6 of this subchapter for information on obtaining the forms you will need to declare and report activities involving Schedule 3 chemicals.

(b) You must complete the Certification Form, Forms 3–1, 3–2, 3–4, Form A if you produced at one or more plants on your plant site any quantity

of a Schedule 3 chemical at any time since January 1, 1946, for chemical weapons purposes. Form B is optional. You must declare the total quantity of such chemical produced, rounded to the nearest tenth of a metric ton (or 100 kilograms). You are not subject to routine inspection unless you are a declared facility pursuant to § 714.2.

§ 714.2 Initial and annual declaration  
requirements for plant sites that  
produce a Schedule 3 chemical in  
excess of 30 metric tons.

(a) *Declaration of production of Schedule 3 chemicals for purposes not prohibited by the CWC.* (1) *Production quantities that trigger the declaration requirement.* You must complete the appropriate forms specified in paragraph (b) of this section if you have produced or anticipate producing a Schedule 3 chemical as follows:

(i) *Initial declaration.* You produced at one or more plants on your plant site in excess of 30 metric tons of any single Schedule 3 chemical during calendar year 1996.

(ii) *Annual declaration on past activities.* You produced at one or more plants on your plant site in excess of 30 metric tons of any single Schedule 3 chemical during the previous calendar year, beginning with 1997.

(iii) *Annual declaration on anticipated activities.* You anticipate that you will produce at one or more plants on your